

Supplementary Information for “Magnetotransport and magnetic properties of amorphous NdNi₅ thin films”

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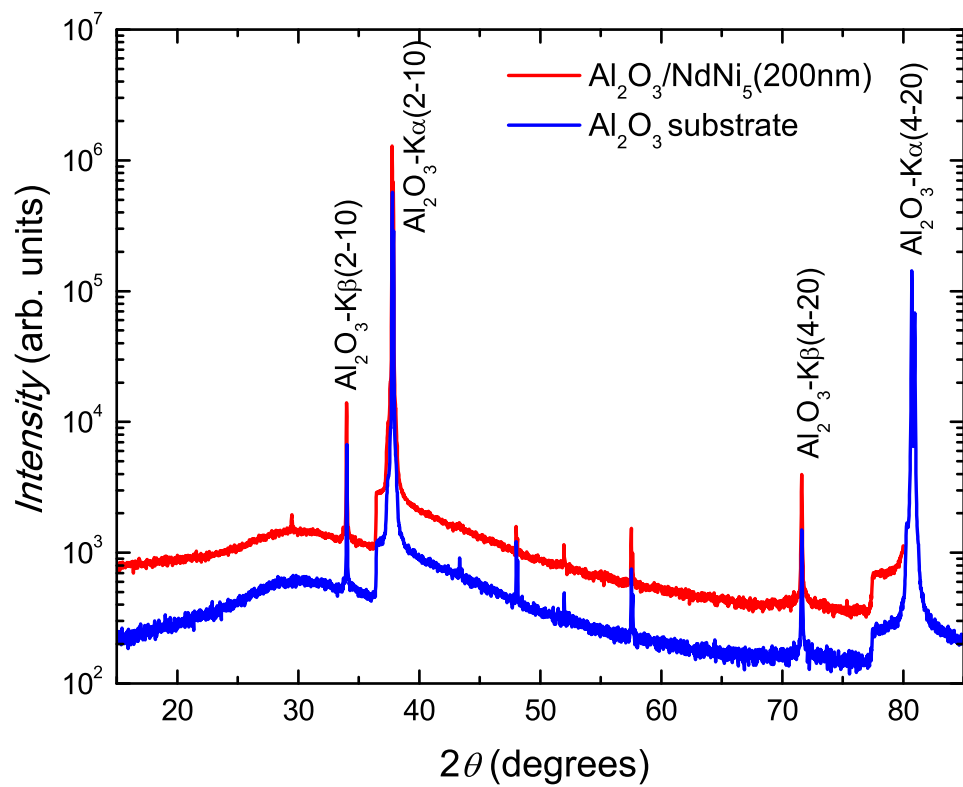


Fig. S1. **Structural characterization.** High-angle X-ray diffraction data from a 200-nm-thick NdNi₅ film deposited on Al₂O₃(1120) (red curve). The blue curve is the trace from the bare substrate.